

Refine Search

Search Results -

Terms	Documents
semiconductor and (trench or groove) and pad and mask and etch	4

Database:

US Pre-Grant Publication Full-Text Database
US Patents Full-Text Database
US OCR Full-Text Database
EPO Abstracts Database
JPO Abstracts Database
Derwent World Patents Index
IBM Technical Disclosure Bulletins

Search:

L6

[Refine Search](#)[Recall Text](#)[Clear](#)[Interrupt](#)

Search History

DATE: Wednesday, July 14, 2004 [Printable Copy](#) [Create Case](#)

Set Name Query

side by side

Hit Count Set Name

result set

*DB=JPAB; PLUR=YES; OP=ADJ*L6 semiconductor and (trench or groove) and pad and mask and etch4 L6*DB=EPAB; PLUR=YES; OP=ADJ*L5 semiconductor and (trench or groove) and pad and mask and etch2 L5*DB=USPT; PLUR=YES; OP=ADJ*L4 semiconductor and (trench or groove) and pad and mask and etch4420 L4*DB=PGPB; PLUR=YES; OP=ADJ*L3 semiconductor and (trench or groove) and pad and mask and etch1907 L3*DB=TDBD; PLUR=YES; OP=ADJ*L2 semiconductor and (trench or groove) and pad and mask and etch6 L2*DB=DWPI; PLUR=YES; OP=ADJ*L1 semiconductor and (trench or groove) and pad and mask and etch204 L1

END OF SEARCH HISTORY